

Spin Transport in Epitaxial Heusler Alloy/ III-V Semiconductor Heterostructures

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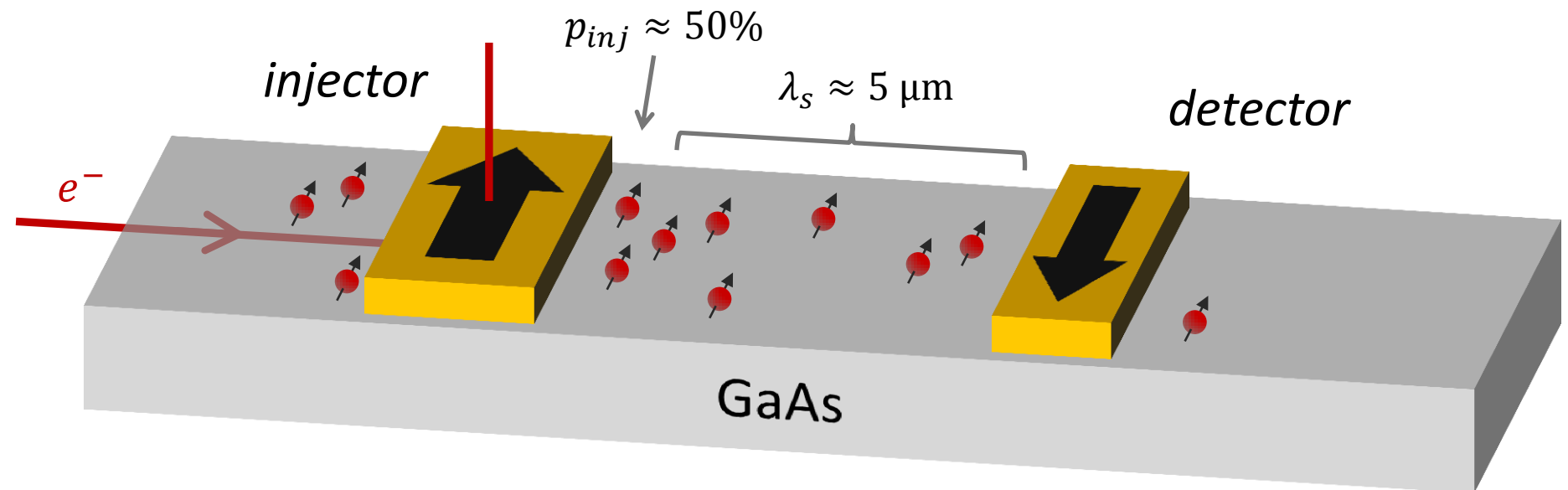
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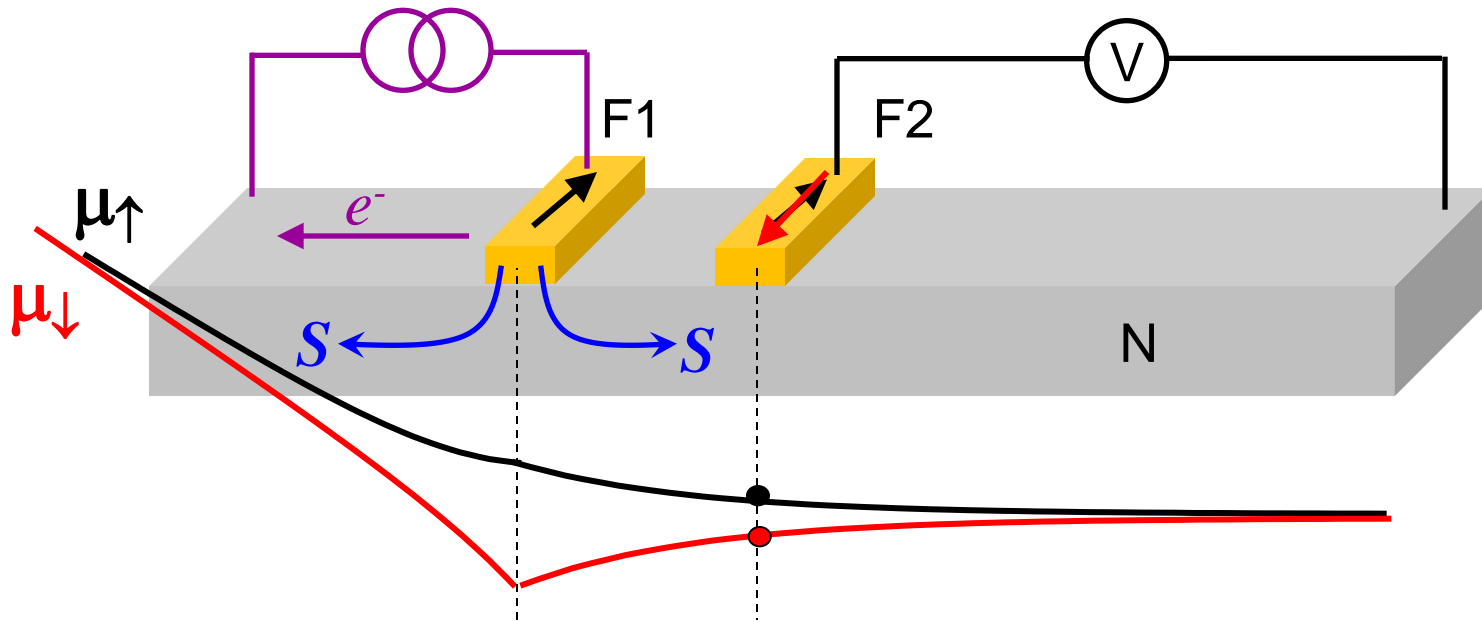
- **Why lateral spin valves**
- Why Heuslers: the $\text{Co}_2\text{Fe}_x\text{Mn}_{1-x}\text{Si}$ family
- Progress in semiconductor lateral spin valves
- Improvements in high temperature performance
- Microwave detection of spin accumulation

Lateral spin valve

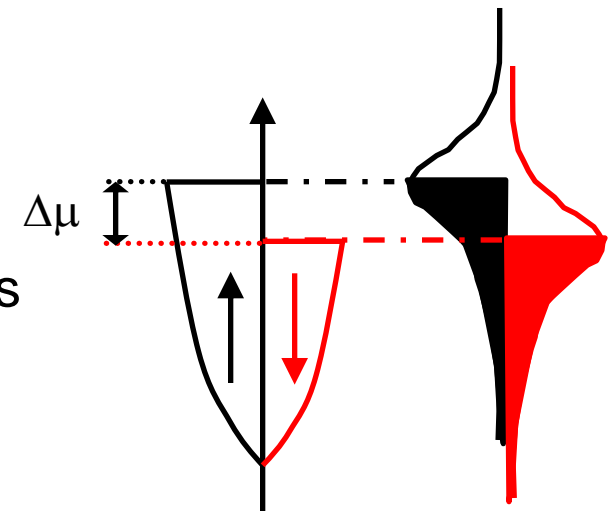
- Allows the study of spin-physics in wide array of materials systems
 - ferromagnetic contacts (Fe, Co, Py, Co₂MnSi, etc.)
 - metallic channels (Al, Cu, Ag, etc.); $p \ll 1\%$
 - semiconducting channels (GaAs, Si, Ge, graphene, etc.)
- Can quantify injection rates, detection efficiencies, spin-lifetimes, etc.



The non-local measurement



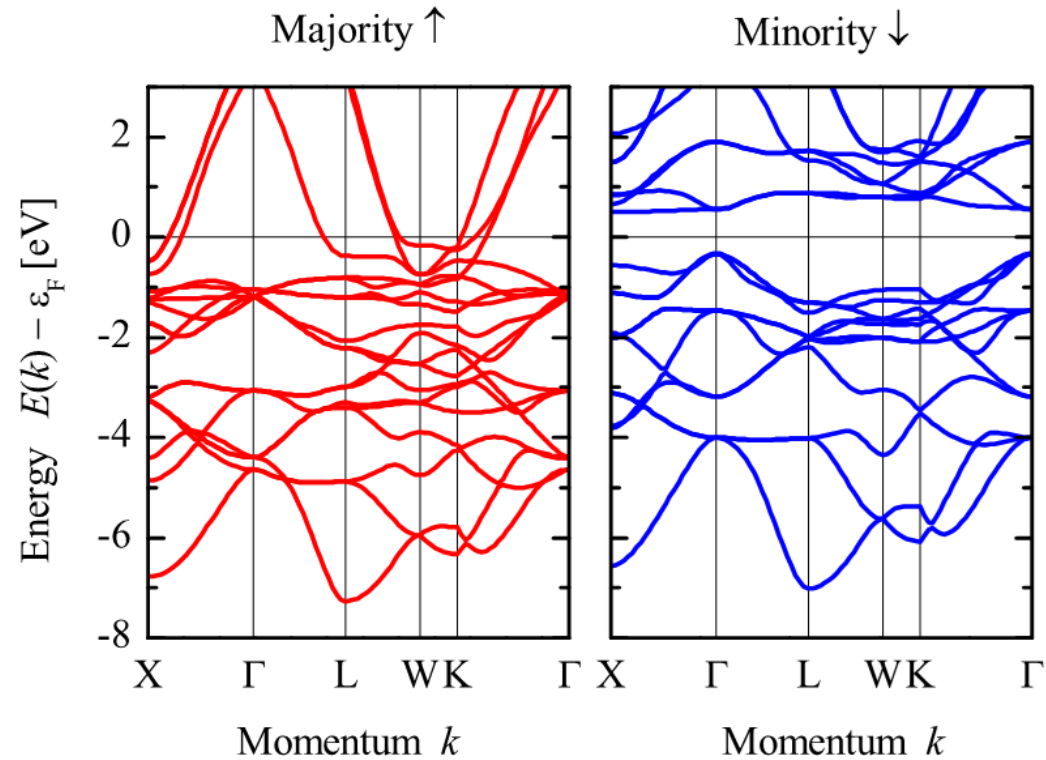
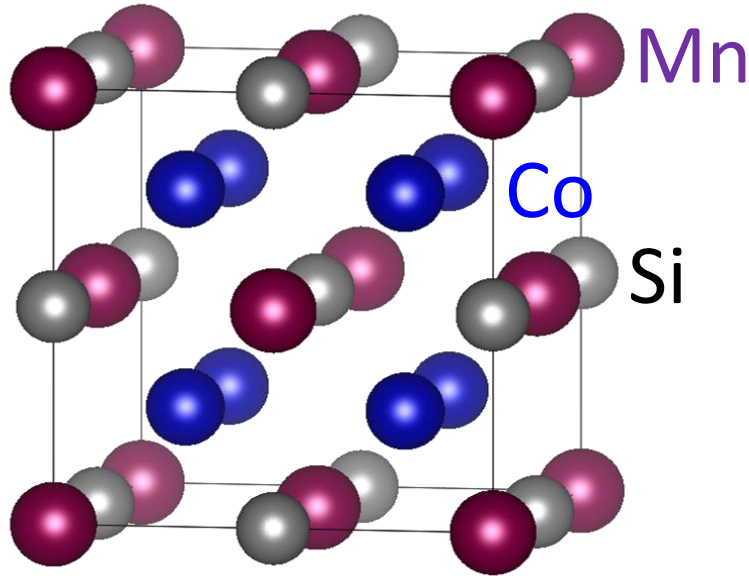
- No *charge* current flows in F2.
- The electrochemical potential is measured for each state of F2 (seemingly straight-forward).
- The (less than 100%) polarization of F2 reduces the signal from the ideal value.
- F2 draws a spin current. This can perturb N (irrelevant in this system)



Outline

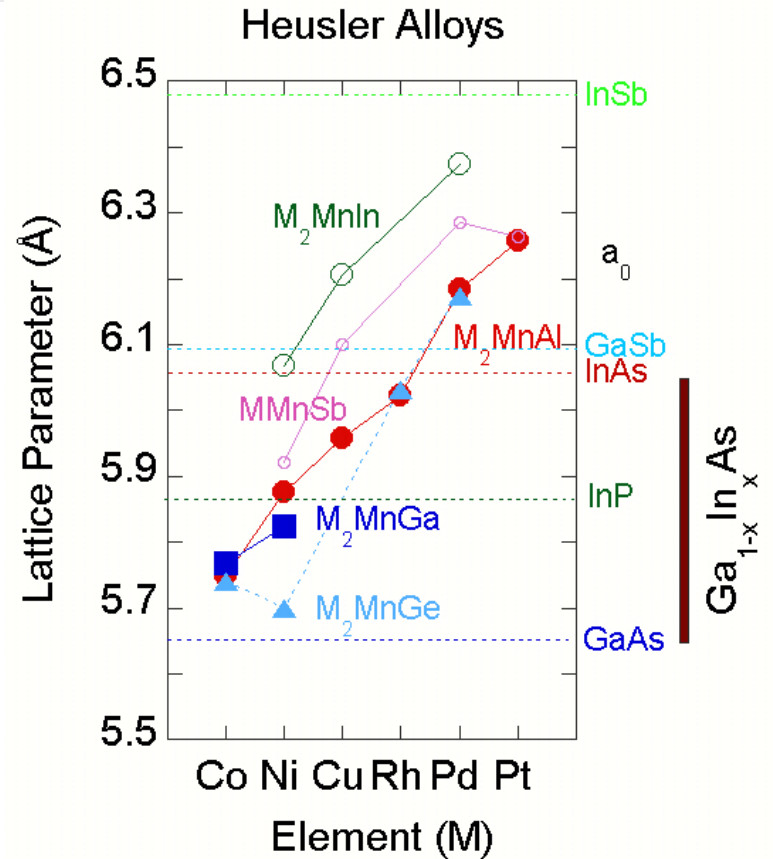
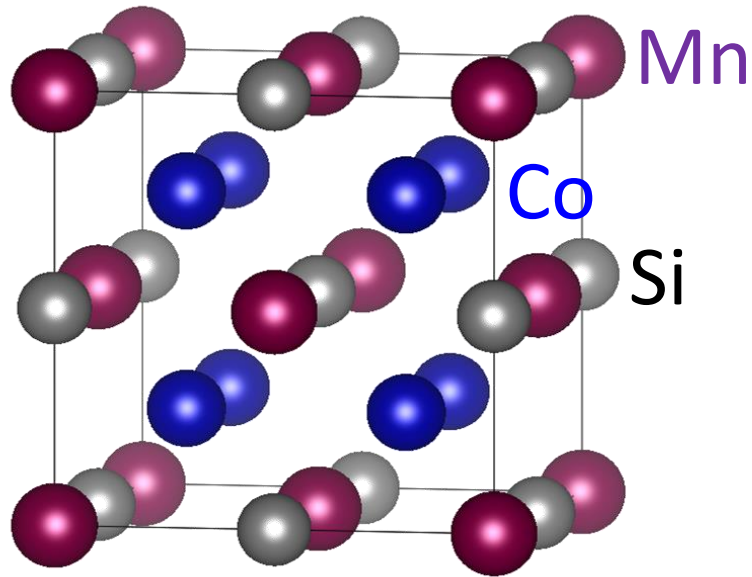
- Why lateral spin valves
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Co₂MnSi – a potential half-metal



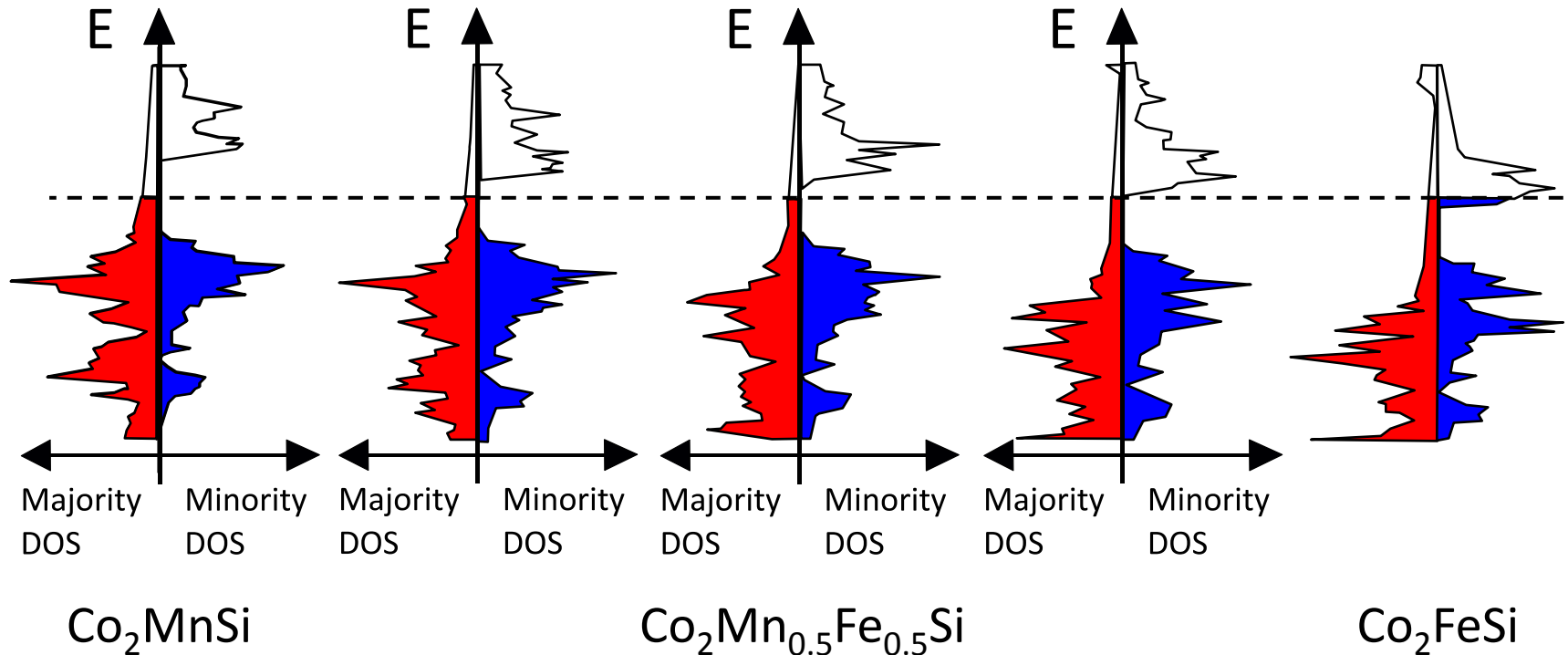
- Predicted to be a half-metal with a relatively large minority gap
- Lattice-matched to GaAs

Co₂MnSi – a potential half-metal



- Predicted to be a half-metal with a relatively large minority gap
- Lattice-matched to GaAs
- Spin injection will work [see Dong *et al.*, Appl. Phys. Lett. **86**, 102107 (2006) for Co₂MnGe/GaAs]

General idea: Fermi level in a rigid band model



- Can we tune the Fermi level through the minority spin gap?

B. Balke *et al.*, Solid State Communications **150**, 529–532 (2010).

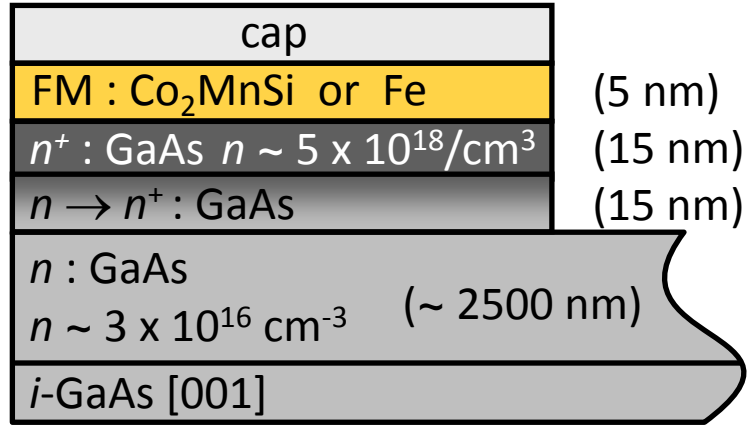
Useful features of these alloys

- As indicated by work on MTJ's, the tunneling polarization is high; Co_2MnSi is half-metallic or nearly so.
- As suggested by the cartoons on the previous viewgraphs, the density of states at the Fermi level is relatively small. This is a corollary to the fact that E_F changes so rapidly with composition.
- Grown on (100) GaAs, they have a very large in-plane uniaxial anisotropy. This turns out to be of practical utility.
- The LLG damping is particularly small for Co_2MnSi (~ 0.003 at high temperatures)

Outline

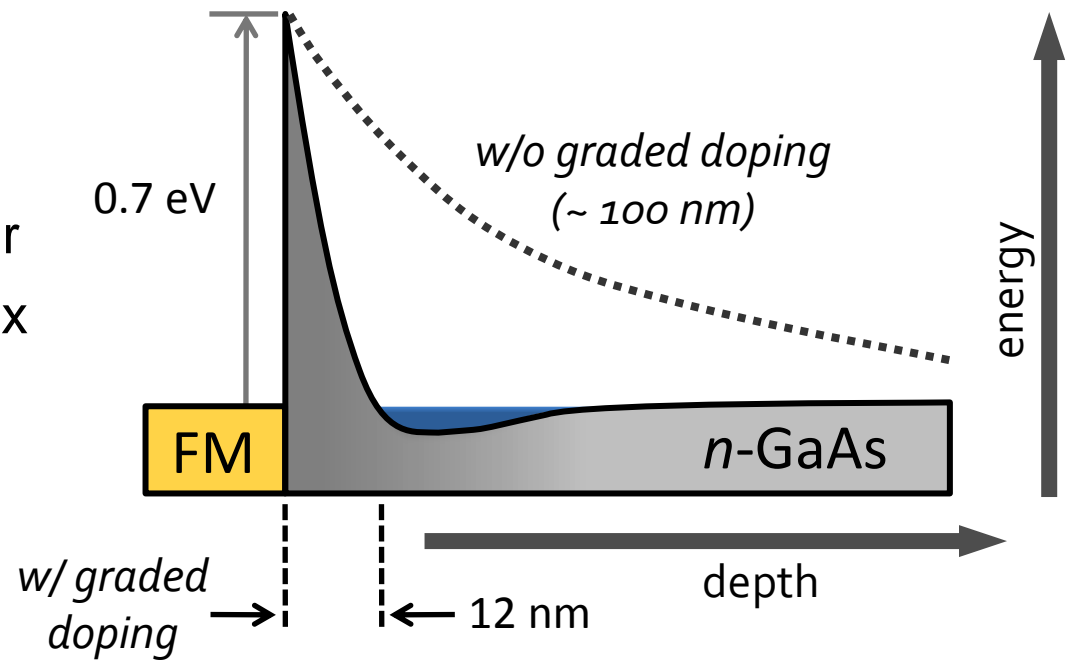
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FM/*n*-GaAs Heterostructures

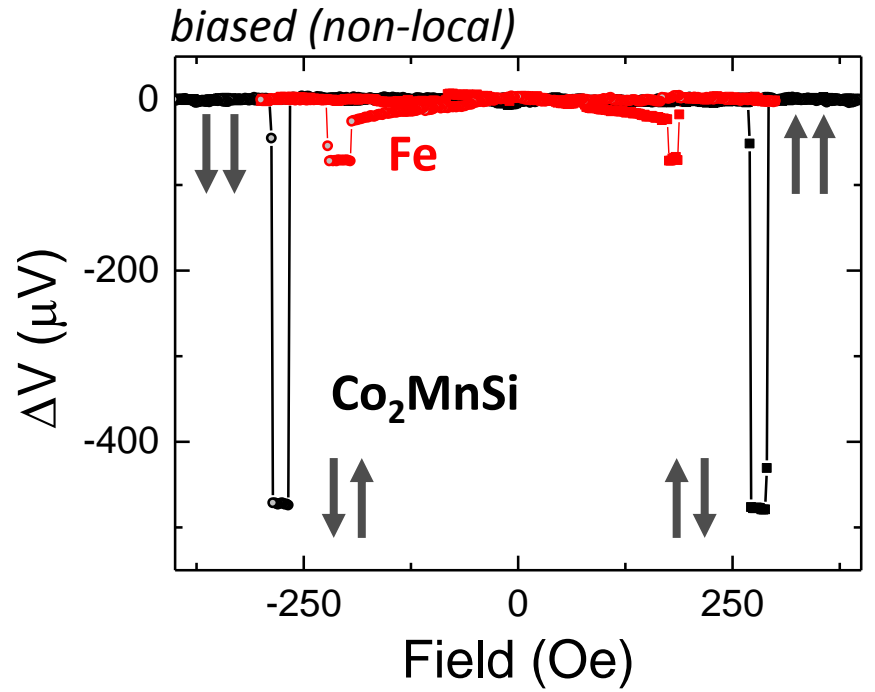
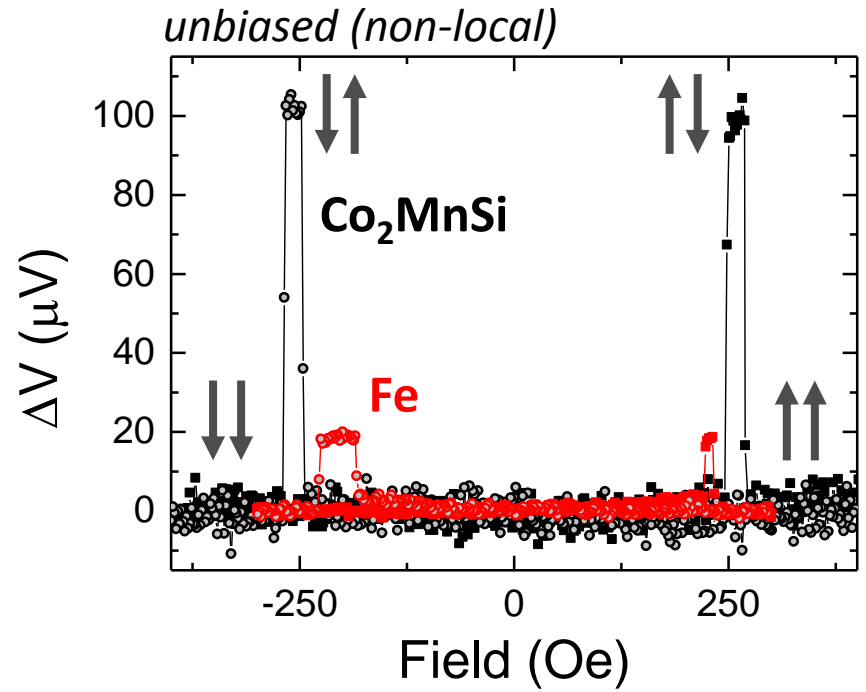
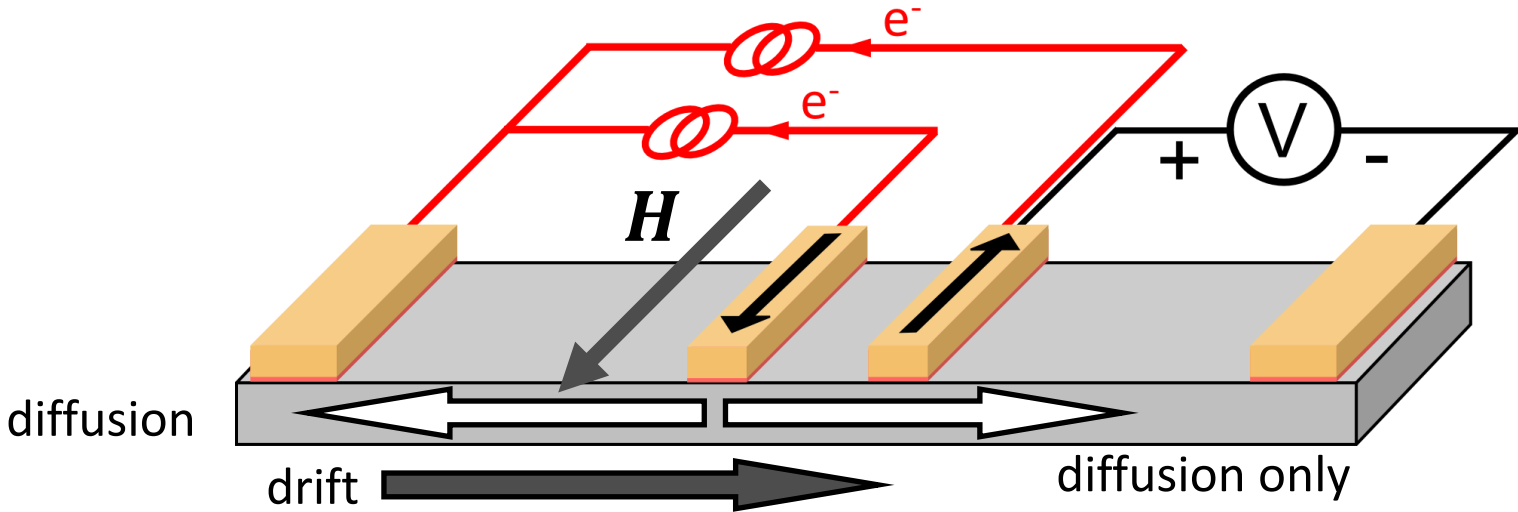


- Epitaxially grown along [001]
- Fe polarization at Fermi level ≈ 40%
- Co₂MnSi proposed to be half-metallic
- Surface-induced FM anisotropy

- Graded doping used to ‘thin’ natural forming Schottky barrier
- Interface states lead to complex bias dependence



Lateral spin valve



Spin drift-diffusion model

DIFFUSION CONSTANT – Same for spin and charge?

$$eD = v n \frac{\partial \mu}{\partial n}$$

(Einstein relation)

v	drift mobility
n	carrier concentration
$\partial \mu / \partial n$	bulk modulus

steady state

$$0 = \frac{\partial \vec{p}}{\partial t} = \underbrace{vE \frac{\partial \vec{p}}{\partial x} + D \frac{\partial^2 \vec{p}}{\partial x^2}}_{\text{drift \& diffusion}} - \underbrace{\gamma \vec{B} \times \vec{p}}_{\text{Larmor precession}} - \underbrace{\frac{\vec{p}}{\tau_s}}_{\text{relaxation}} + \underbrace{\dot{\vec{p}}_0}_{\text{injection rate}}$$

SPIN LIFETIME – Reasonable values for n-GaAs?

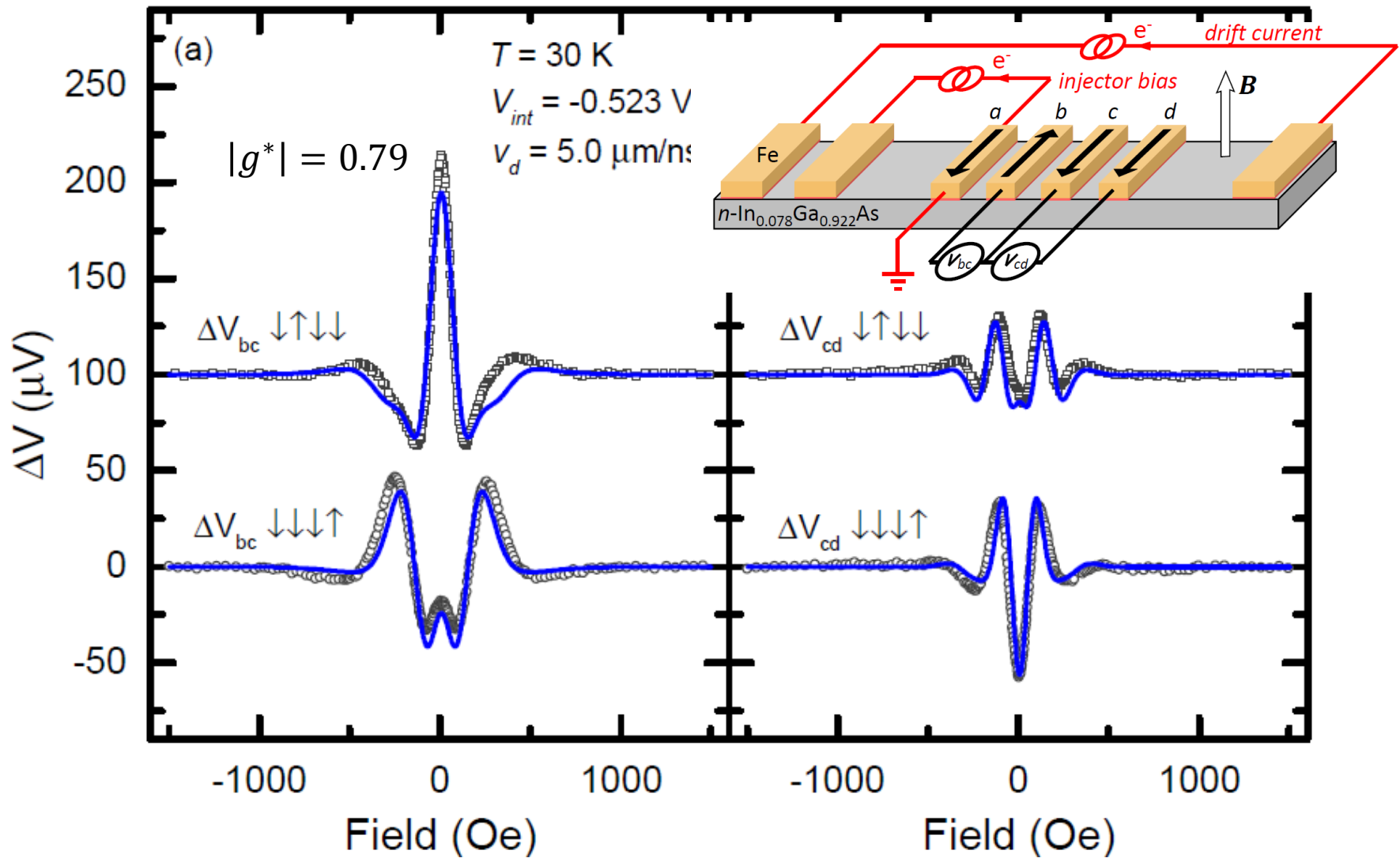
$$\tau_s^{-1} \propto \alpha^2 \varepsilon^3 \tau_p$$

(Dyakonov-Perel)

ε	electron energy
α	spin-orbit prefactor (Dresselhaus)
τ_p	momentum relaxation time

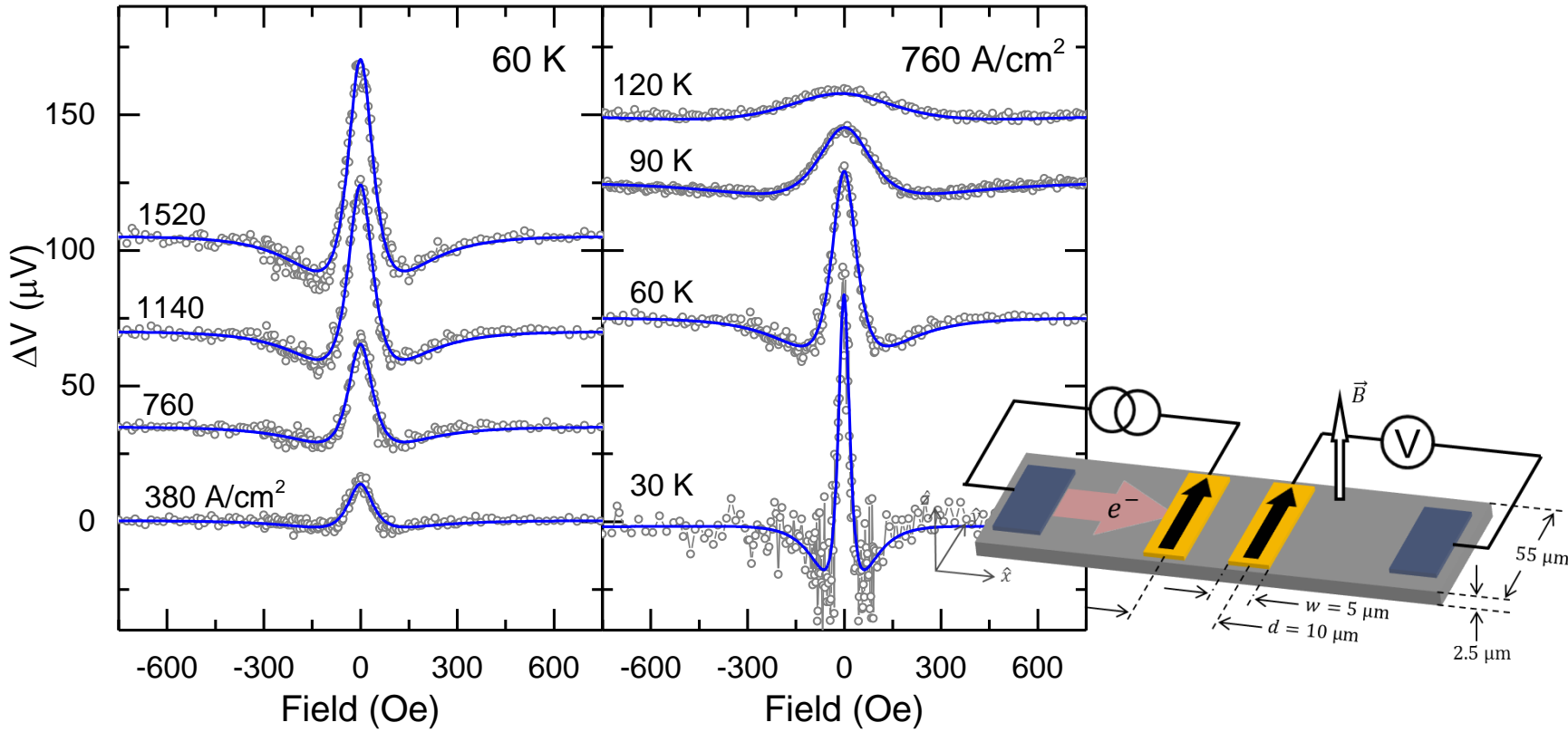
D d
 τ_s s
 \vec{p} fr
 E e
 v m
 γ gyromagnetic ratio
 \vec{B} magnetic field

The full time of flight experiment: add drift



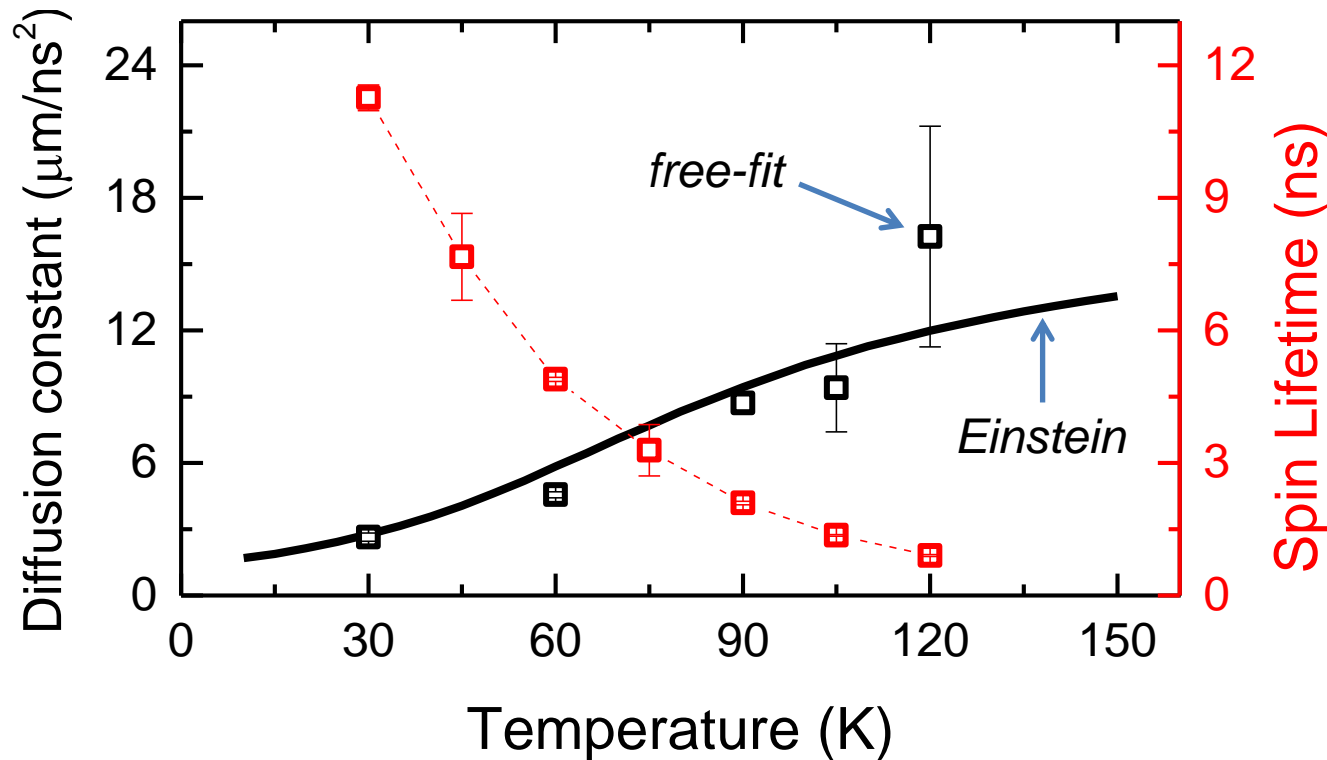
- Solid curves are the analytic solution

Non-local Hanle fitting



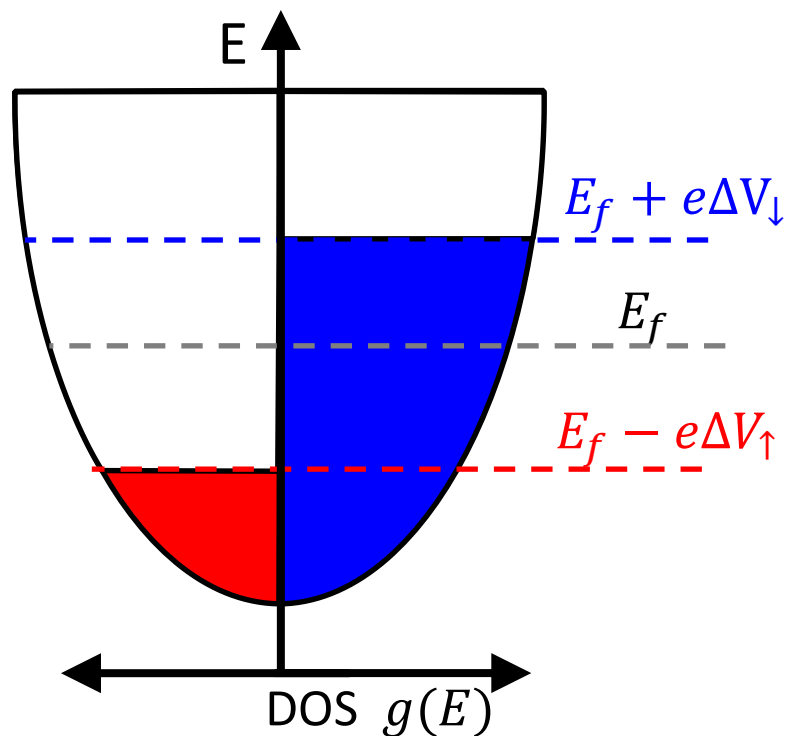
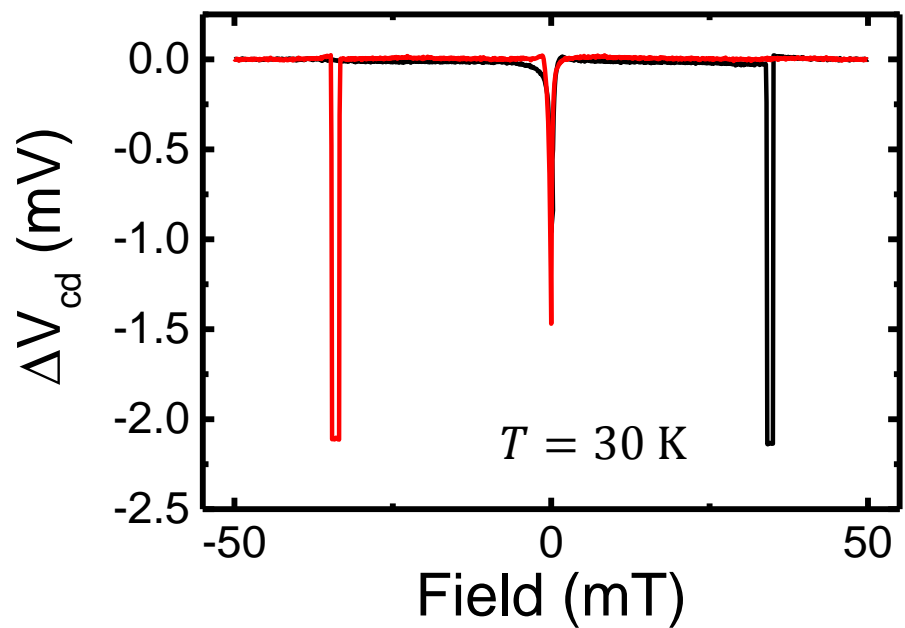
- Multiple biases at each temperature fit with a single set of parameters
- Hanle curves with 'lobes' allow extraction of diffusion constant

Spin lifetime and diffusion constant



- Allowing D to be a fitting parameter yields values in agreement with the Einstein relation: spin and charge diffusion constants are the same.
- Larger uncertainty at higher temperatures due to disappearance of 'lobes'

Estimates of the spin polarization



- We can set a lower bound for the spin-polarization if we assume a perfect detection efficiency ($\eta = 1$)

$$n_{\uparrow(\downarrow)} = \int_{E_f \pm \frac{e\Delta V}{\eta}} g(E) dE$$
- The measured spin-splitting ΔV is half of the Fermi energy $E_f = 5 \text{ meV}$

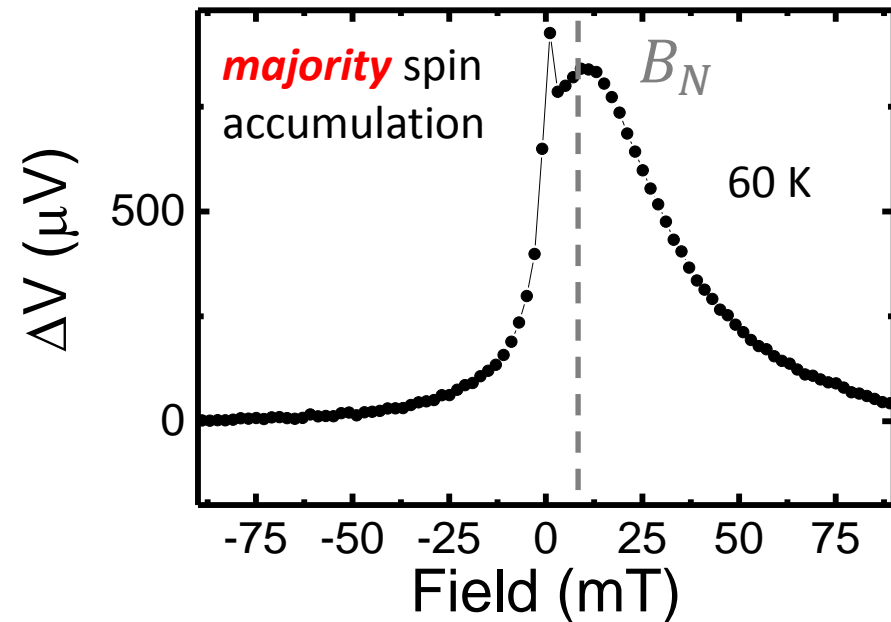
$$p = \frac{n_{\uparrow} - n_{\downarrow}}{n_{\uparrow} + n_{\downarrow}} = 60\%$$

$$\eta = 1$$

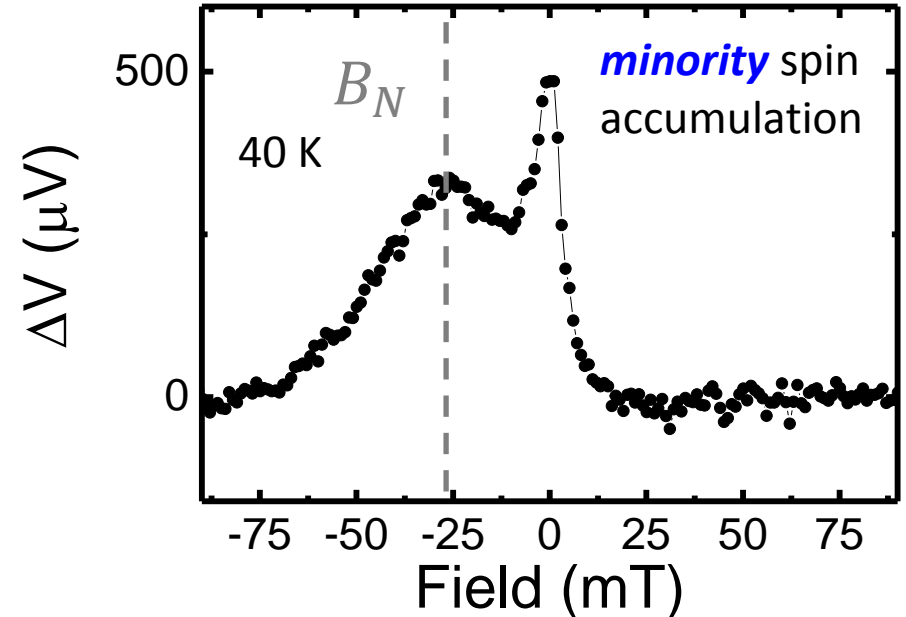
Sign of the spin accumulation by Hanle measurements

Exploit hyperfine coupling:

Co₂MnSi/GaAs



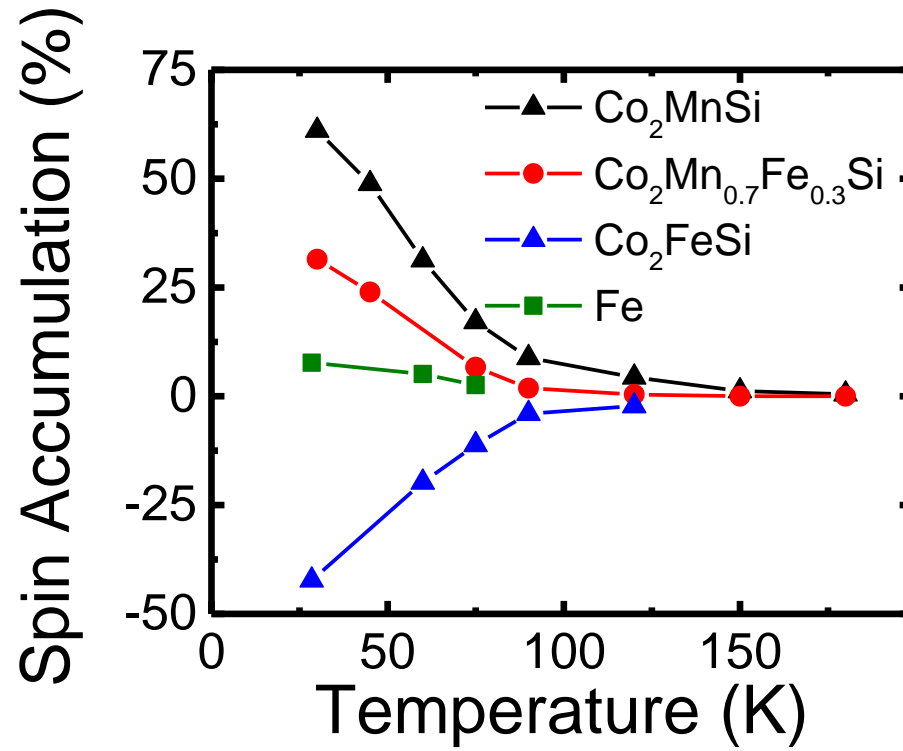
Co₂FeSi/GaAs



Sign of the spin polarization in the bulk GaAs can be determined in the presence of a hyperfine field

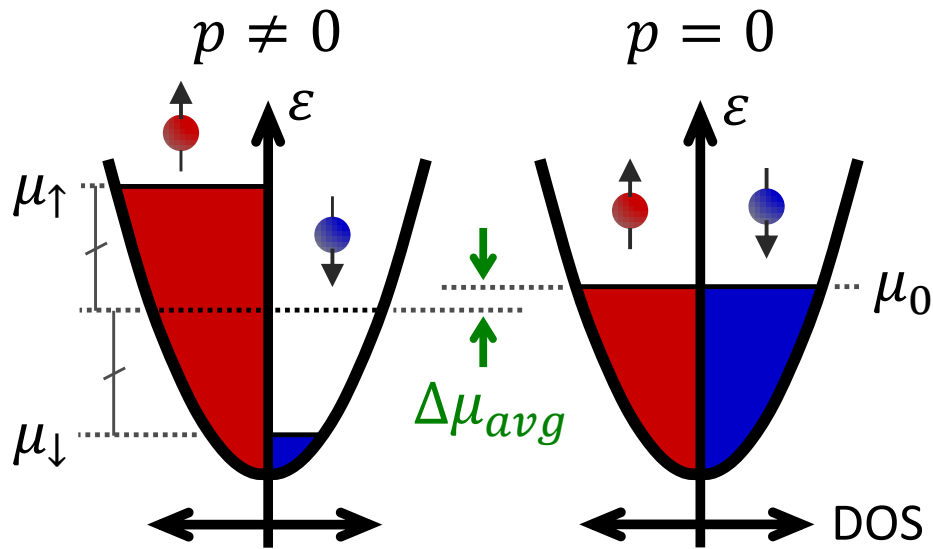
$$\vec{B}_{tot} = \vec{B} - b_H \frac{\vec{S} \cdot \vec{B}}{B^2} \vec{B}$$

$\text{Co}_2\text{Mn}_{1-x}\text{Fe}_x\text{Si}$: comparison with Fe



- Polarizations determined by “biased detector technique”
- Sign determined by hyperfine field
- Sign change in going from Co_2MnSi to Co_2FeSi is expected, but overall sign is *backwards*

Interlude: (Scalar) Spin EMF



- Current in each spin-channel:

carrier densities \downarrow electrostatic potential \downarrow

$$\vec{j}_{\uparrow(\downarrow)} = n_{\uparrow(\downarrow)} \nu \vec{\nabla} [\mu_{\uparrow(\downarrow)} - e\Phi]$$

spin-indep. mobility \nearrow chemical potentials \nearrow

- Expand chemical potentials w.r.t. p :

$$\mu_{\uparrow(\downarrow)} \approx \mu_0 + (-) \frac{\partial \mu}{\partial n} np + \underbrace{\frac{\partial^2 \mu}{\partial n^2} n^2 p^2}_{\text{asymmetric shift: } \Delta\mu_{avg}}$$

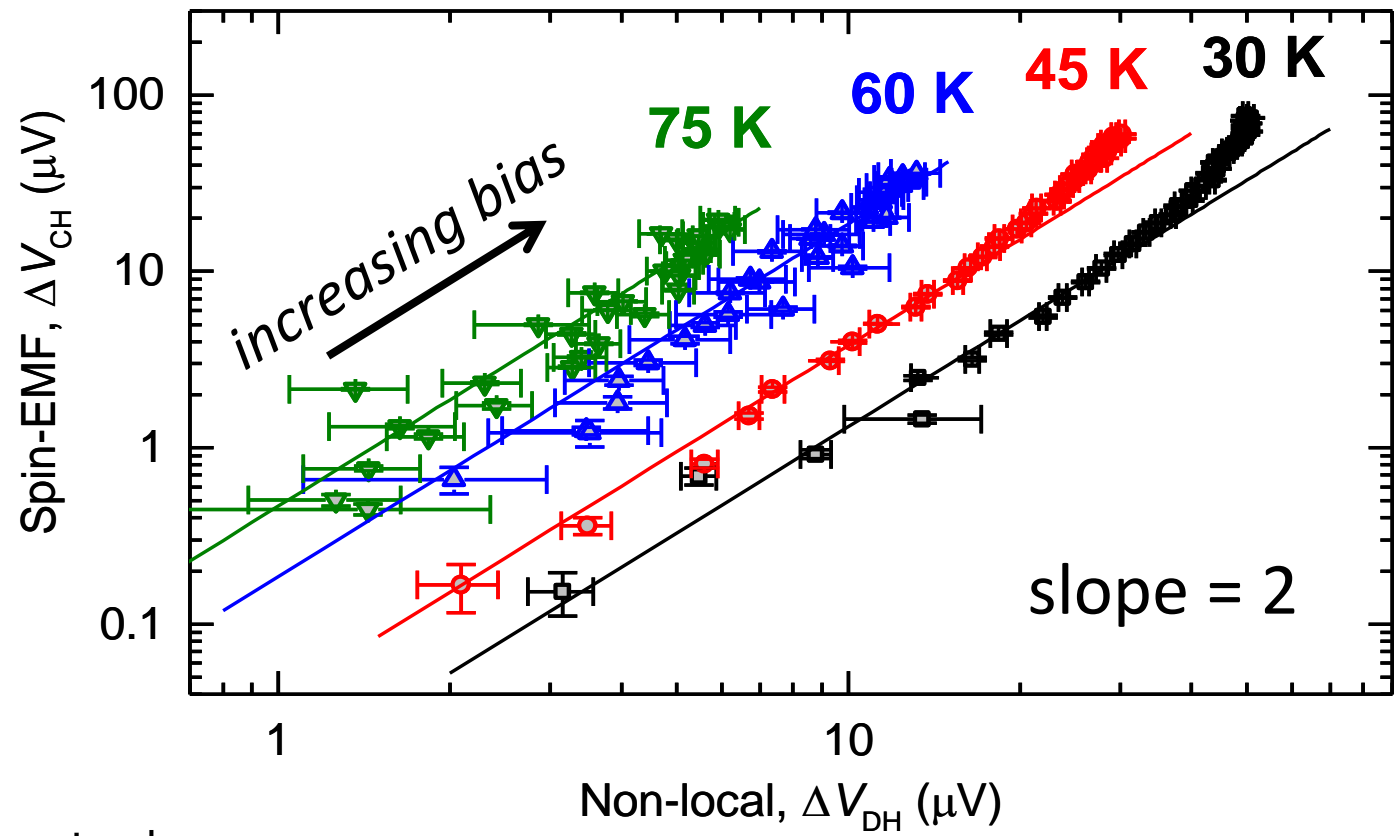
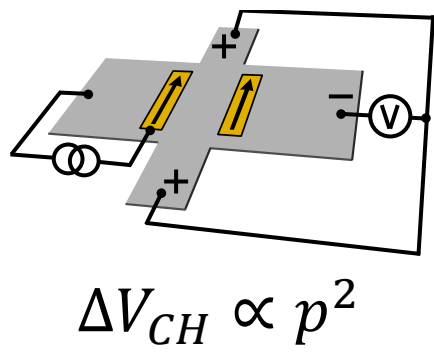
- Result:

spin-generated EMF \downarrow

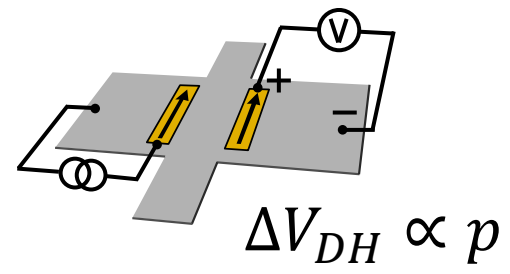
$$\vec{j} = \sigma \vec{\nabla} (kp^2 - \Phi)$$

$$k = \frac{1}{2e} \left(\frac{\partial \mu}{\partial n} n + \frac{\partial^2 \mu}{\partial n^2} n^2 \right) = \frac{2 E_f}{9 e}$$

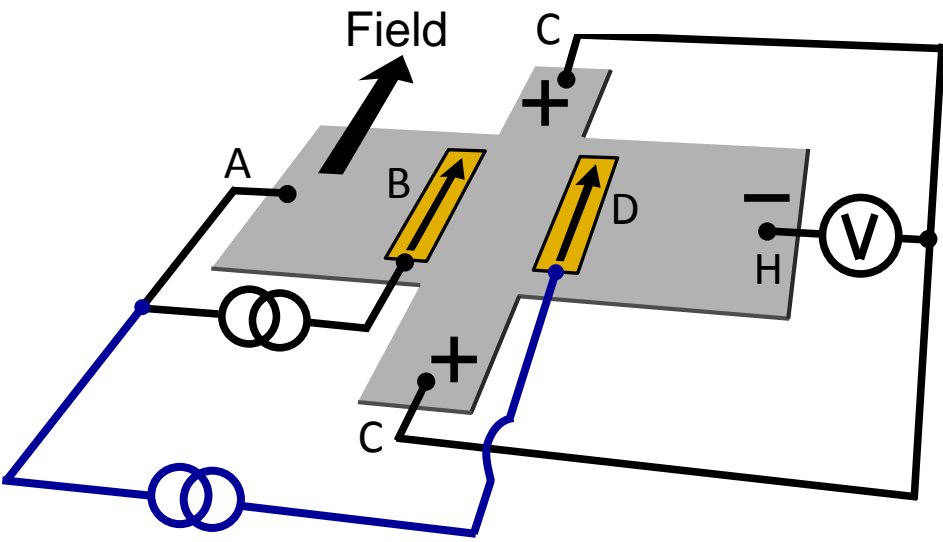
Quadratic dependence



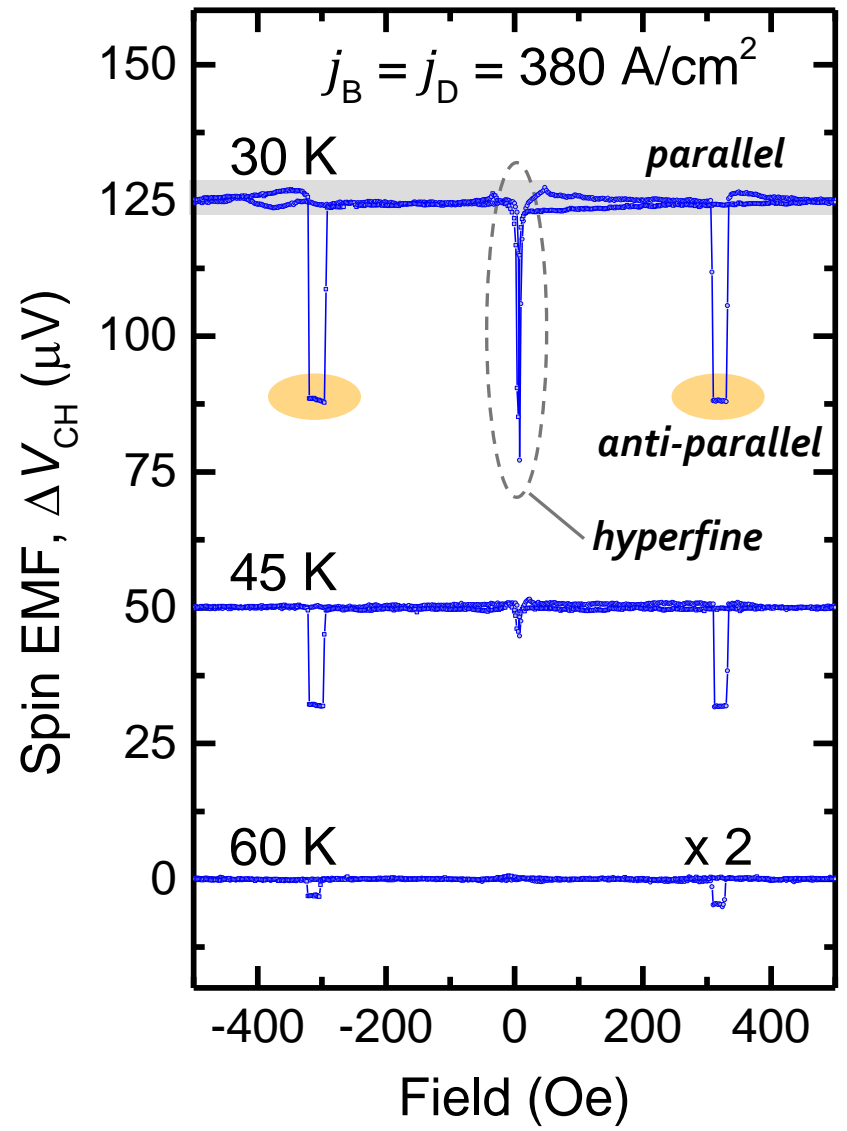
- Log-log plot of magnitudes demonstrates quadratic dependence
- Deviation at large bias due to large E-field at injector (drift effects)



Dual-injector experiment

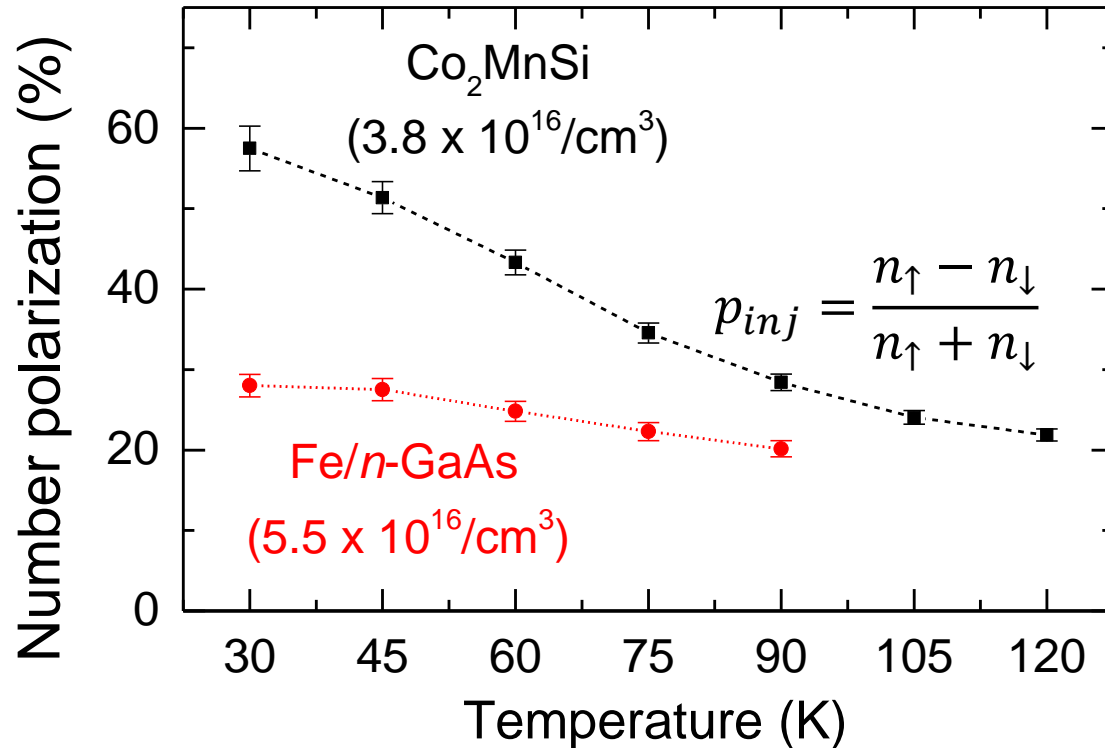


- Spins injected simultaneously at FM contacts B and D
- Clear spin valve signals observed at contact C
- Low-field features due to hyperfine interactions



I. J. Vera-Marun *et al.*, Nature Phys. **8**, 313 (2012).

Polarization vs. Temperature



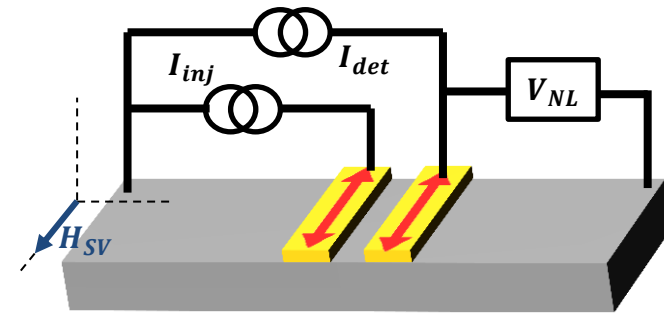
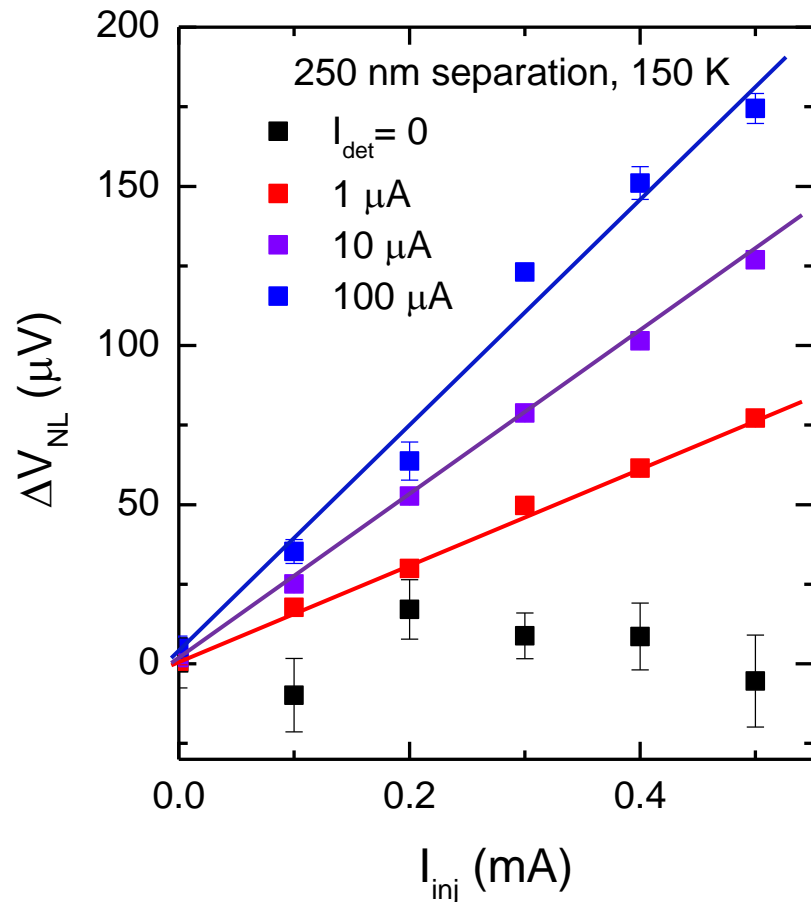
- For $p > 0.3$, need to account for ‘Thompson’ effect: $k = k(p)$
- Results are independent of any assumptions about interfacial spin injection/detection efficiencies
- This resolved the “three-terminal” discrepancy

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What about room temperature?

- Biased detector



- ΔV_{NL} is linear in spin injection rate, I_{inj} , with fixed non-zero detector bias I_{det}
- ΔV_{NL} becomes larger with detector bias I_{det} , which we interpret as a detector bias dependence of $\eta \rightarrow \eta(I_{det})$

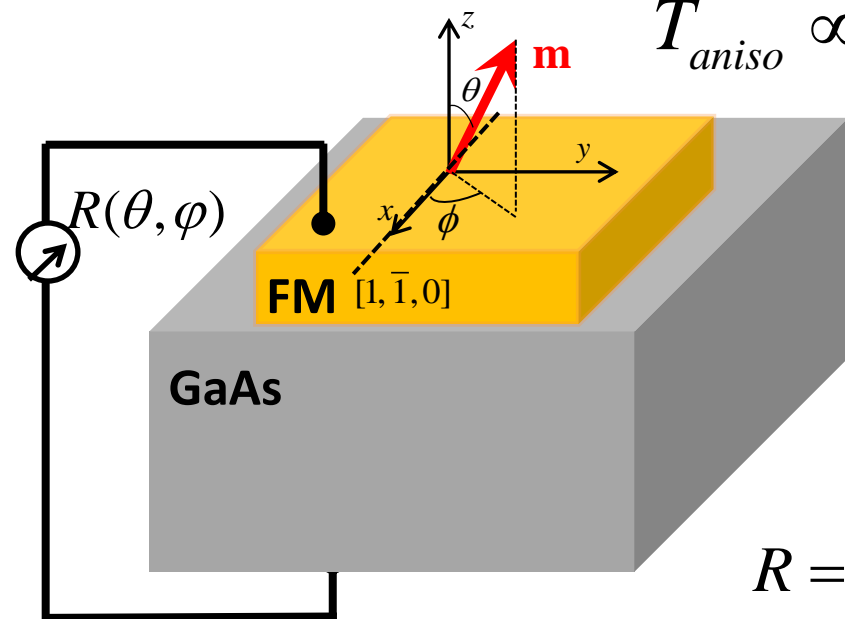
$$\Delta V_{NL} = \eta(I_{det}) \frac{P(I_{inj})n}{e} \frac{\partial \mu}{\partial n}$$

- We also see saturation of ΔV_{NL} at large I_{det} .

Complication: Tunneling AMR (TAMR)

$$\frac{e}{(2\pi)^3 \hbar} \sum_{\sigma} \int dE d^2 k_{\parallel} T_{\sigma}(E, k_{\parallel}) [f_F(E_{\sigma}) - f_N(E)]$$

$$T_{aniso} \propto \sin^2(\theta) [f(\alpha, \gamma) + g(\alpha, \gamma) \cos(2\phi)]$$



α : Rashba spin-orbit coupling constant

γ : Dresselhaus spin-orbit coupling constant

$$R = R_0 + \Delta R_{in} \sin^2(\theta) \cos^2(\phi) + \Delta R_{out} \sin^2(\theta)$$

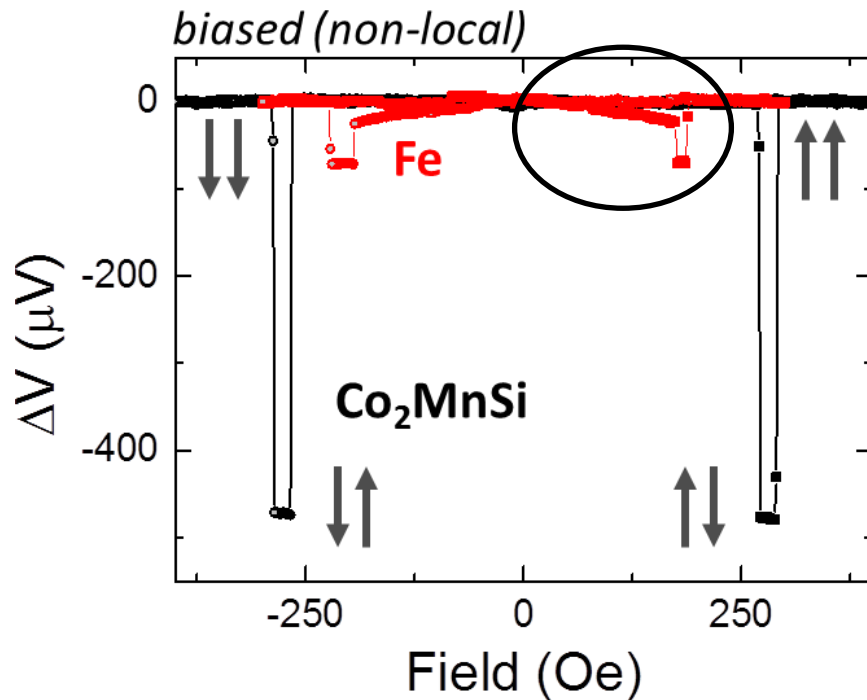
J. Moser et al., *PRL*, **99**, 056601 (2007)

A. Matos-Abiague et al., *PRB*, **80**, 045312 (2009)

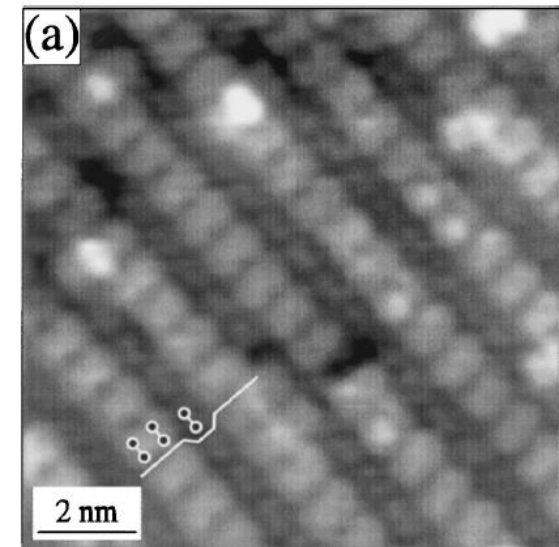
K. Wang et al., *PRB*, **88**, 054407 (2013)

Ramifications for a biased detector

- Any contact rotation leads to a TAMR contribution to the “three-terminal” signal; i.e. an additional field-dependent voltage at the detector. This is large and only weakly temperature-dependent.



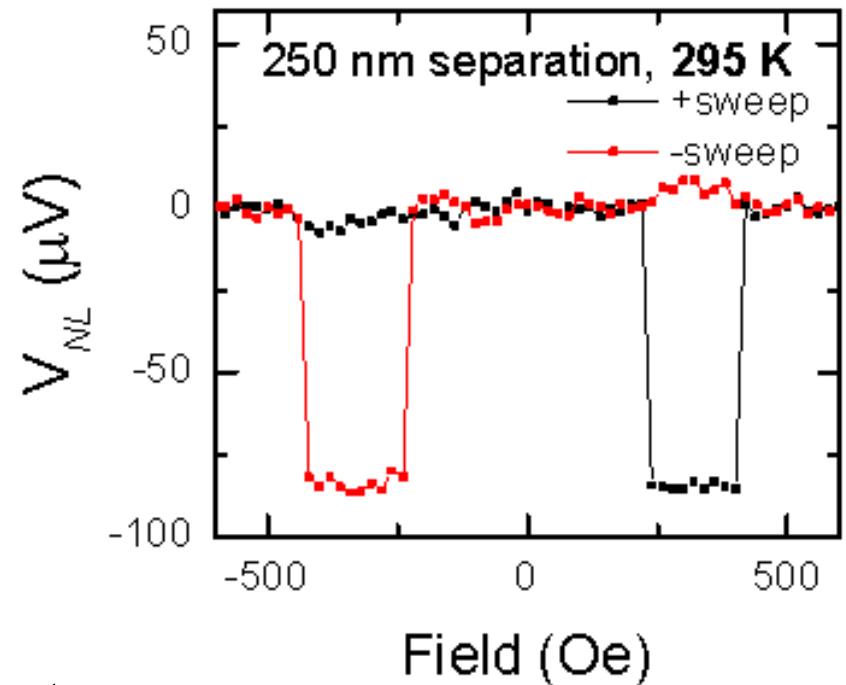
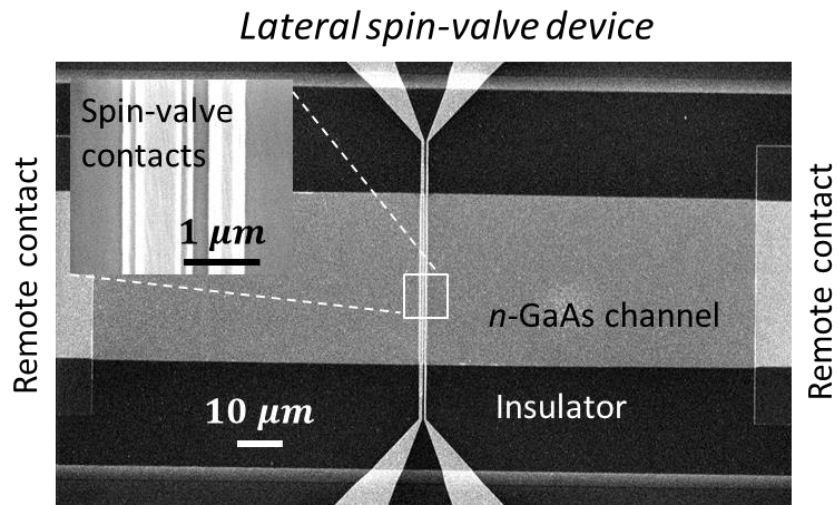
2-fold surface symmetry



La Bella *et al.*, PRL **83**, 2989 (1999).

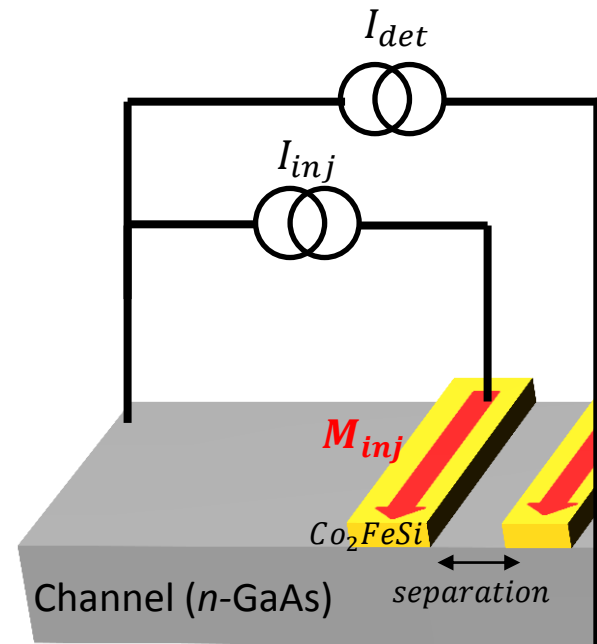
- The ratio of the uniaxial to fourfold anisotropies is larger in Co₂Mn_{1-x}Fe_xSi than in Fe. This makes the Heuslers very forgiving.

Devices operating at room temperature



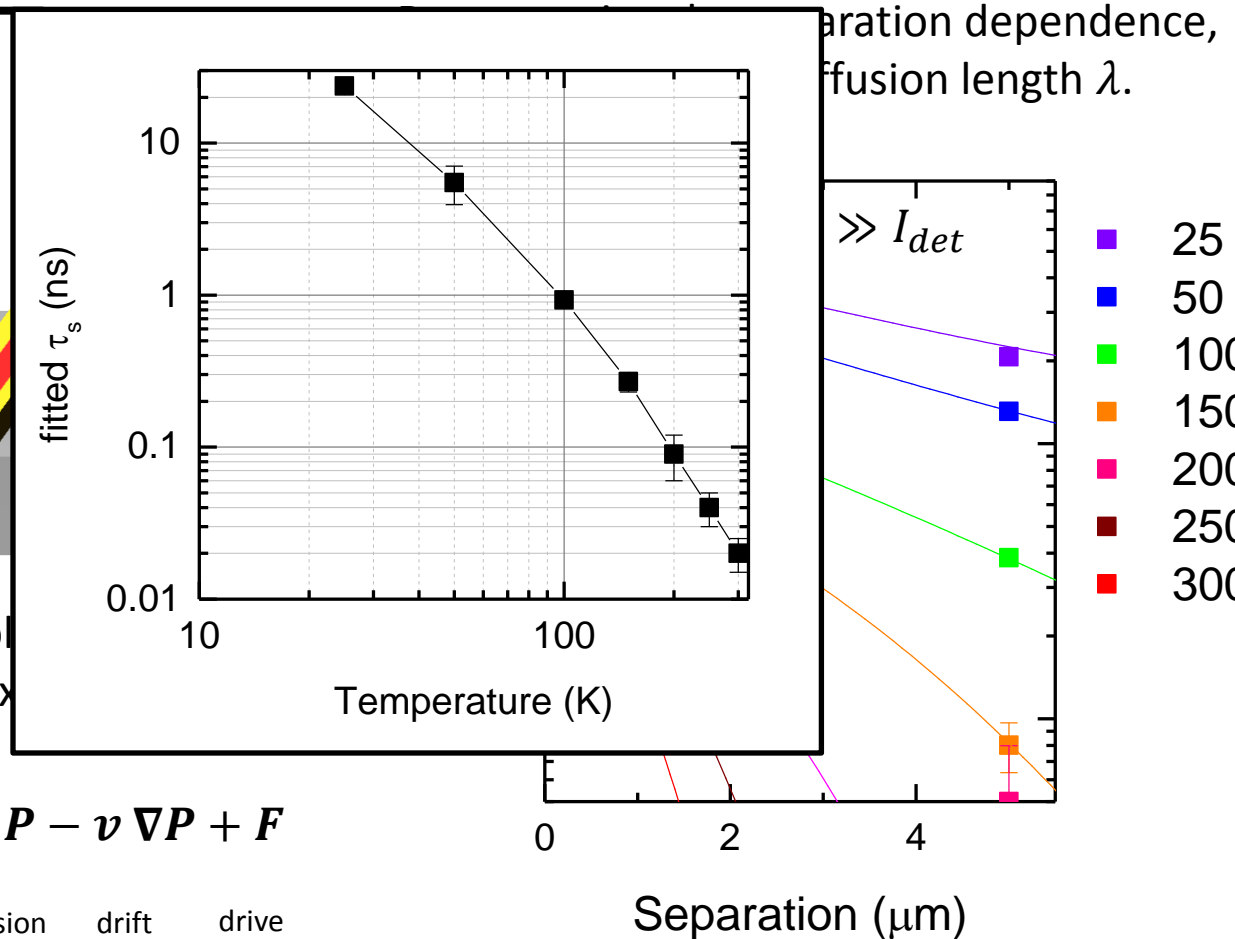
- Use of Co_2FeSi as injector/detector
- Electron beam lithography
- Performance today comparable to low-T performance as of a few years ago (particularly size of non-local voltage)
- Spin diffusion length at 300 K is ~ 800 nm

Temperature dependence



We fit to the steady state solution of the drift-diffusion equation to extract the carrier lifetime τ_s .

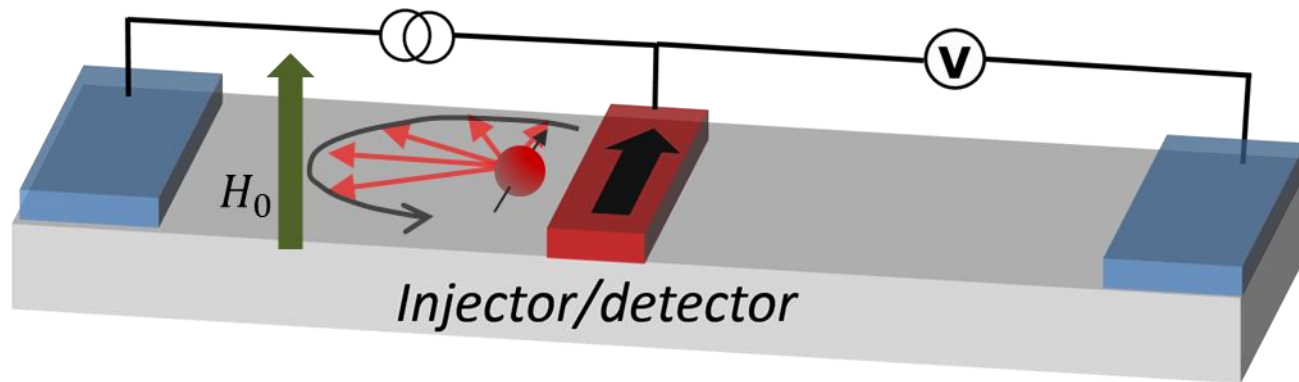
$$\frac{dP}{dt} = 0 = \underbrace{-\frac{P}{\tau_s}}_{\text{relaxation}} + \underbrace{D\nabla^2 P}_{\text{diffusion}} - \underbrace{v\nabla P}_{\text{drift}} + \underbrace{F}_{\text{drive}}$$



Outline

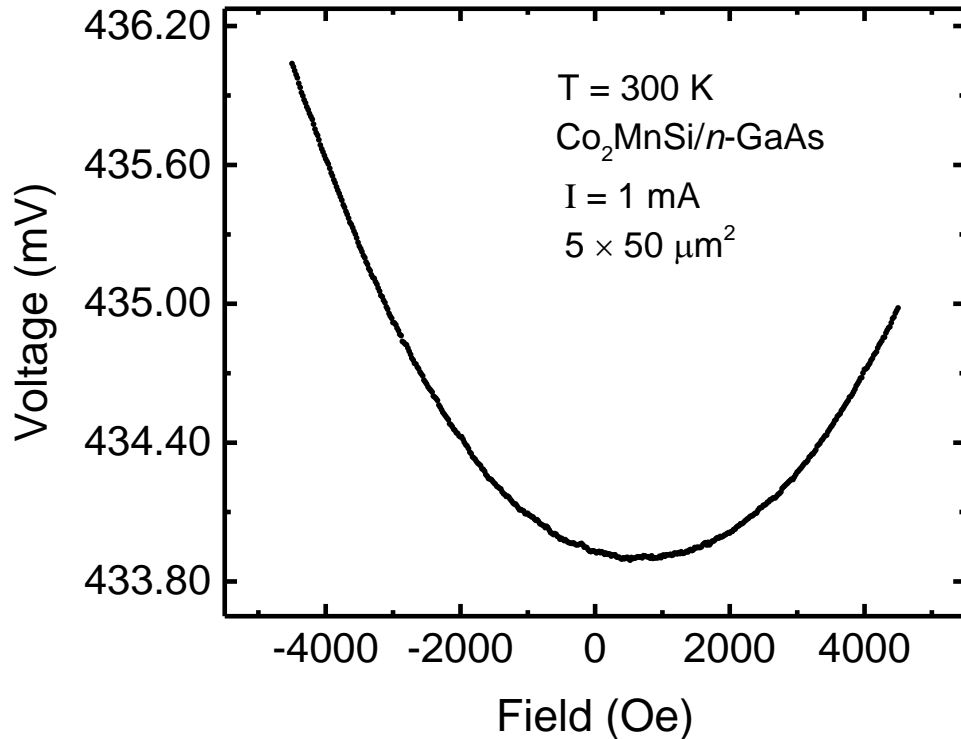
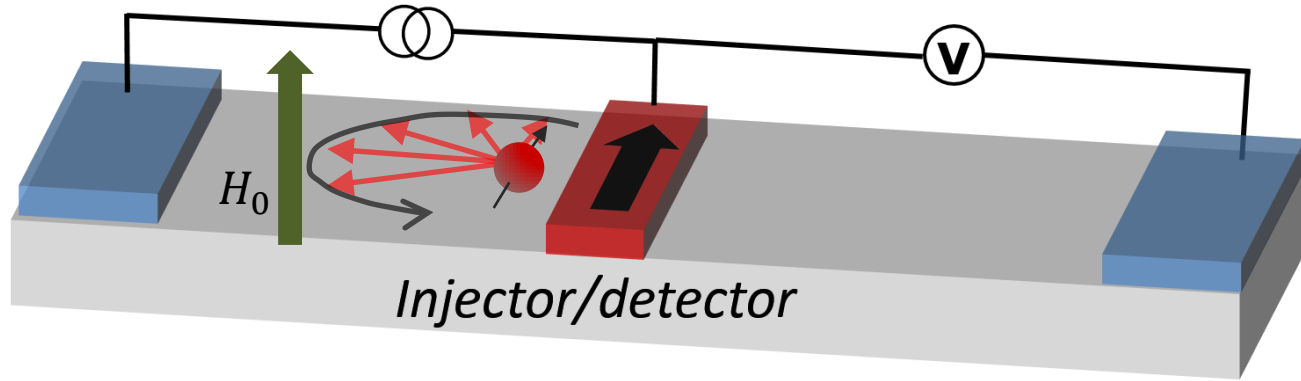
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What about Hanle measurements?



- Conventional wisdom: these become difficult or impossible at high temperatures because the lifetime is “too short”
- This is reinforced by the fact that the g-factor in GaAs is so small (i.e. -0.44 instead of 2)
- Ordinary magnetoresistance is very large

Hanle measurement at room temperature fails

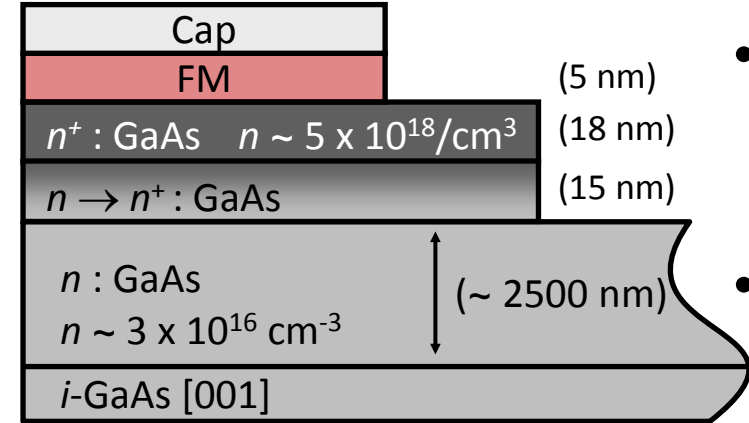


- Signal/Background $\sim 10^{-4}$
- Impossible to extract spin signal at room temperature in n-GaAs system

What about Hanle measurements?

- Conventional wisdom: these become difficult or impossible at high temperatures because the lifetime “is too short”
- This is reinforced by the fact that the g-factor in GaAs is so small (i.e. -0.44 instead of 2)
- Ordinary magnetoresistance is very large
- **Solution: use the Hanle concept (sensitivity to precession), but exploit the fact that spins can precess in the FM as well as the semiconductor.**

Solution: modulate the injector with FMR

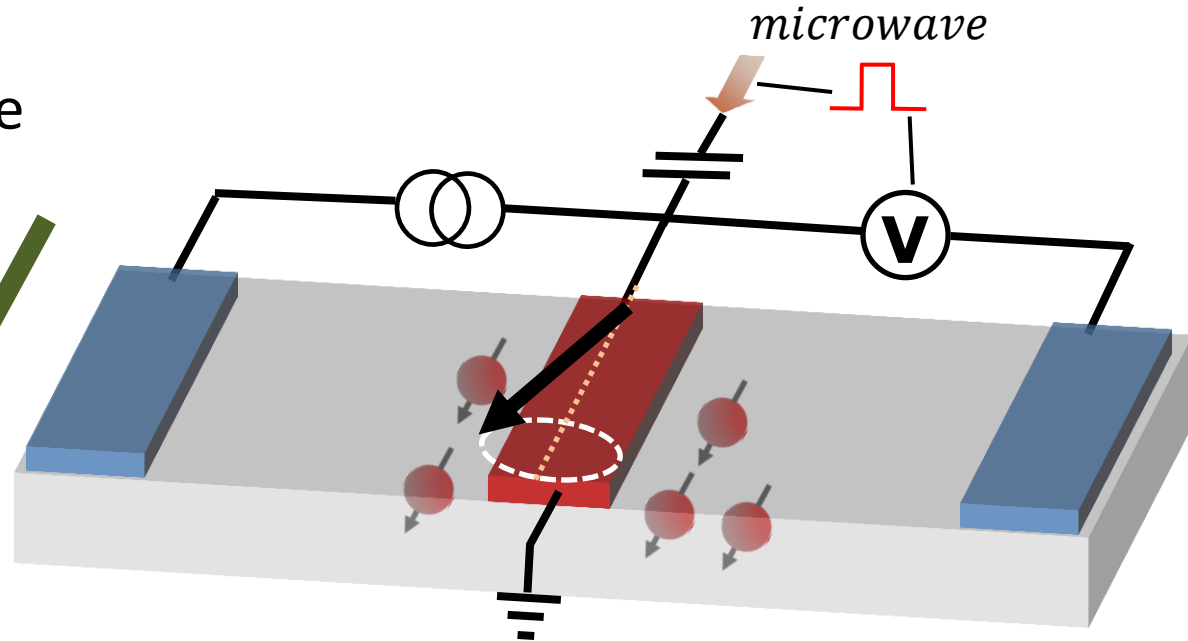


- This is a three-terminal measurement with microwave excitation
- Signal is the difference of the 3T signal with and without microwave field

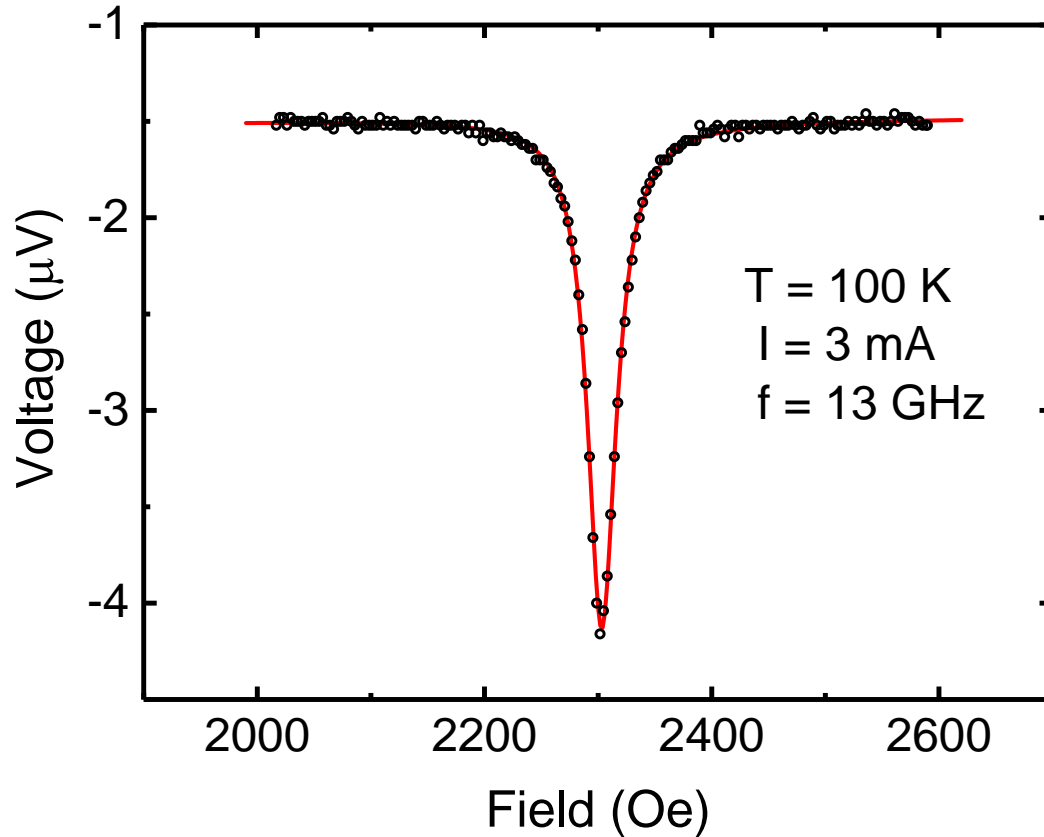
FM: Co_2MnSi , Co_2FeSi , Fe

Skipping details...

H_0

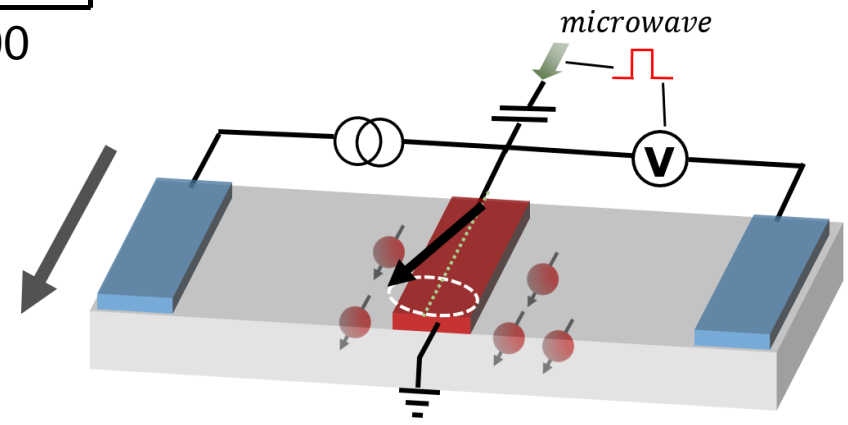


Spin accumulation leads to an FMR peak in ΔV

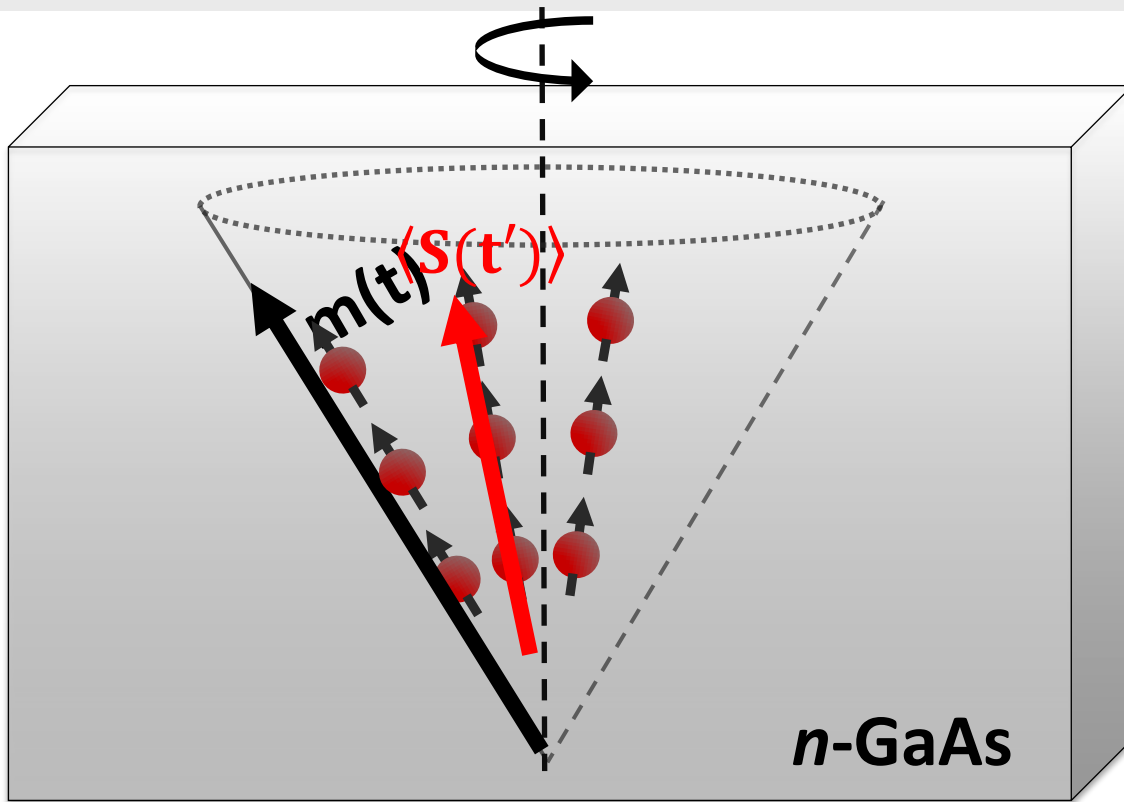


- A strong resonance peak is observed (note the sign is negative)
- The peak position is well described by the Kittel's formula

- At forward bias, the FMR signal is dominated by spin accumulation
- Linewidth determined by $\alpha \sim 0.003$ for Co_2MnSi at room temperature



Modeling FMR spin detection

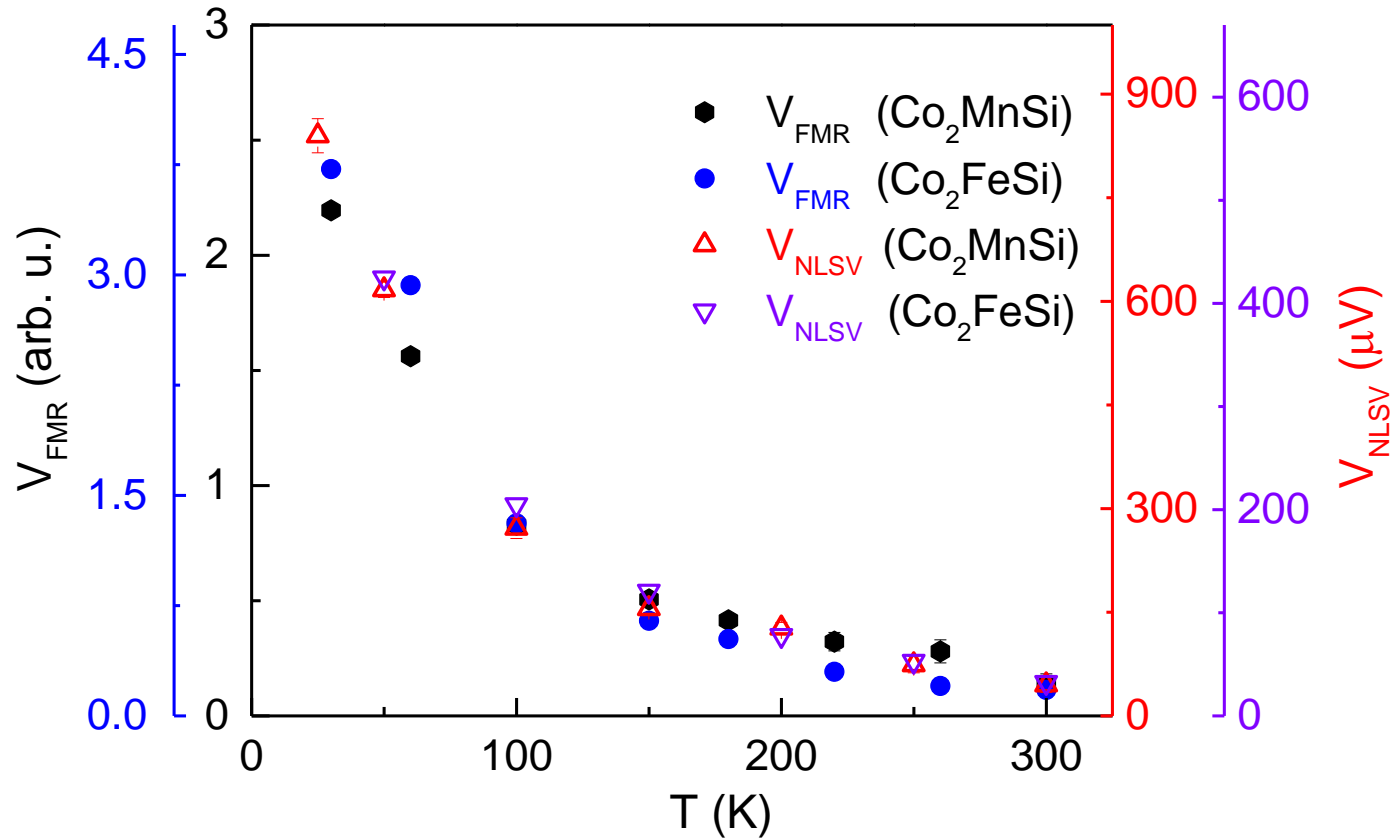


- I_s : Spin injection current
- η : Detection efficiency
- D : Spin diffusion constant
- τ_s : Spin lifetime
- φ_{in} φ_{out} : Precession cone angles

$$V = \eta I_s \int_{-\infty}^t \hat{\mathbf{m}}(t) \cdot \hat{\mathbf{s}}(t') \frac{1}{\sqrt{2\pi D(t-t')}} e^{-\frac{t-t'}{\tau_s}} dt'$$

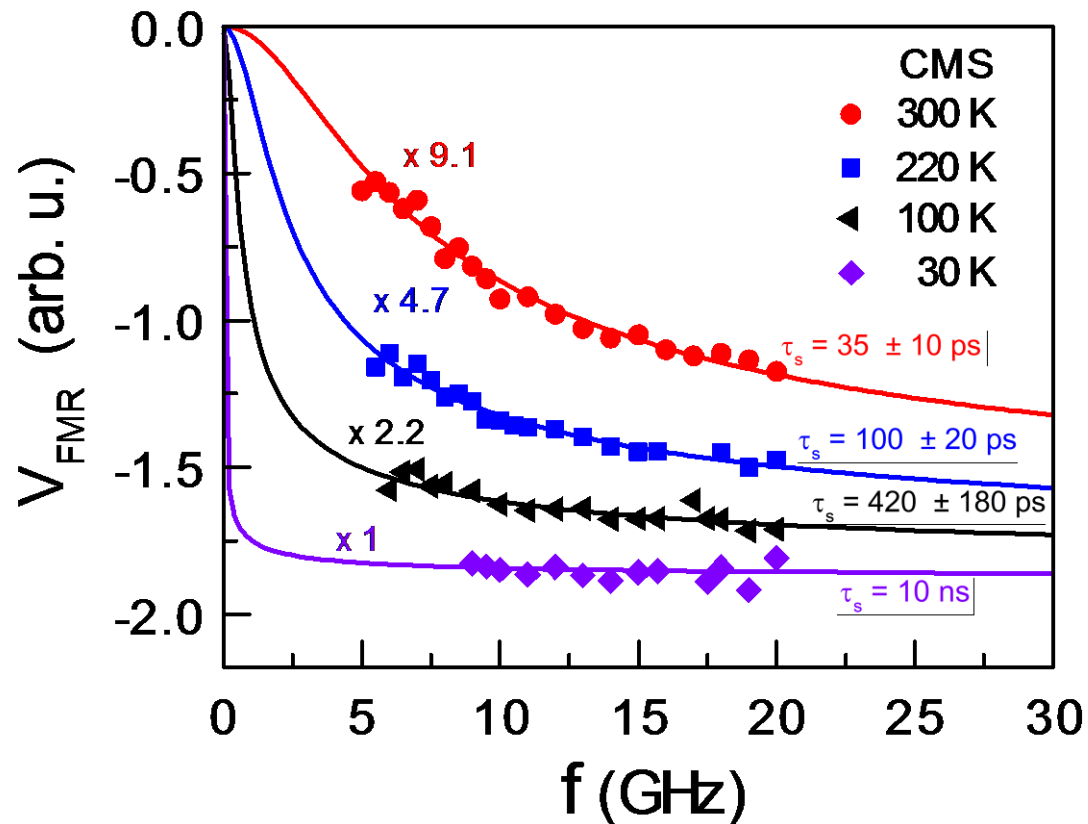
$$V_{FMR} = \eta I_s \frac{1}{2} (\varphi_{in}^2 + \varphi_{out}^2) \sqrt{\frac{\tau_s}{2D}} \left(\sqrt{\frac{1}{2\sqrt{1 + \omega^2 \tau_s^2}} + \frac{1}{2(1 + \omega^2 \tau_s^2)}} - 1 \right)$$

Temperature dependence (comparison with NLSV)



- Agreement with spin-valve data for both Co_2FeSi and Co_2MnSi

Frequency dependence



- Spin lifetime extracted agrees with those obtained from spin-valve measurements
- At high temperatures, this technique is much more sensitive than the conventional spin valve approach

Summary

- $\text{Co}_2\text{Mn}_{1-x}\text{Fe}_x\text{Si}$ is a very effective spin injector/detector for GaAs
- The high polarization helps, although in our case the highest polarizations *measured* are about 70%
- There are other features of these materials that are as “useful” as the high polarization
- Lateral spin valves useful as quantitative tools up to room temperature
- Microwave detection of spin accumulation is a complementary technique, particularly when τ_s is *short*.